



PATENT
Customer No. 22,852
Attorney Docket No. 04329.3210

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
Takeshi Shibata et al.) Group Art Unit: 2823
Application No.: 10/743,522) Examiner: Nguyen, Khiem D.
Filed: December 23, 2003) Confirmation No.: 7673
For: STENCIL MASK WITH)
CHARGE-UP PREVENTION AND)
METHOD OF MANUFACTURING)
THE SAME)

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT
UNDER 37 C.F.R. § 1.97(b)

Pursuant to 37 C.F.R. §§ 1.56 and 1.97(b)(4), Applicants bring to the attention of the Examiner the document listed on the attached PTO-SB-08. This Information Disclosure Statement is being filed with a Request For Continued Examination (RCE) in the above-referenced application. A copy of the document is enclosed.

Applicants respectfully request that the Examiner consider the document listed on attached Form PTO/SB/08 and indicate that it was considered by making an appropriate notation on this form.

The relevance of the non-English language document is set forth below:

1. Japanese Patent Application KOKAI Publication No. 4-216613 discloses a transmission mask substrate for charged particle exposure in FIG. 4. This mask substrate comprises an upper silicon plate 33 having openings, a lower silicon plate 31, a silicon oxidation film 32 provided between the upper silicon plate 33 and the lower silicon plate 31, and a conductive film 38 provided on the side of the lower silicon plate 31 and the silicon oxidation film 32.

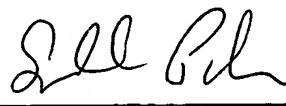
This submission does not represent that a search has been made or that no better art exists and does not constitute an admission that the listed document is material or constitutes "prior art." If the Examiner applies the document as prior art against any claim in the application and Applicants determine that the cited document does not constitute "prior art" under United States law, Applicants reserve the right to present to the Office the relevant facts and law regarding the appropriate status of such document. Applicants further reserve the right to take appropriate action to establish the patentability of the disclosed invention over the listed document, should the document be applied against the claims of the present application.

If there is any fee due in connection with the filing of this Statement, please charge the fee to our Deposit Account No. 06-0916.

Respectfully submitted,

FINNEGAN, HENDERSON, FARABOW,
GARRETT & DUNNER, L.L.P.

Dated: October 13, 2006

By: 
Selah C. Park
Reg. No. 57,127

**INFORMATION DISCLOSURE
STATEMENT BY APPLICANT**

(Use as many sheets as necessary)

Sheet

1 of

**Complete if Known**

Application Number	10/743,522
Filing Date	December 23, 2003
First Named Inventor	Takeshi Shibata
Art Unit	2823
Examiner Name	Nguyen, Khiem D.
Attorney Docket Number	04329.3210

U.S. PATENTS AND PUBLISHED U.S. PATENT APPLICATIONS

Examiner Initials	Cite No. ¹	Document Number	Issue or Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number-Kind Code ² (if known)			
		US-			

Note: Submission of copies of U.S. Patents and published U.S. Patent Applications is not required.**FOREIGN PATENT DOCUMENTS**

Examiner Initials	Cite No. ¹	Foreign Patent Document	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	Translation ⁶
		Country Code ³ Number ⁴ Kind Code ⁵ (if known)				
		JP 4-216613	08-06-1992	Yamazaki Satoru		No

NON PATENT LITERATURE DOCUMENTS

Examiner Initials	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	Translation ⁶

Examiner Signature	Date Considered
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EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.